

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**Applicants:** Matthew J. Breitwisch, et al.      **Examiner:** Douglas W. Owens  
**Serial No.:** 10/710,821      **Art Unit:** 2811  
**Filed:** August 5, 2004      **Docket:** BUR920040015US1 (17427)  
**For:** ISOLATED FULLY DEPLETED SILICON-ON-INSULATOR REGIONS BY  
SELECTIVE ETCH

**Confirmation No.** 6753      **Dated:** October 16, 2006

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO *EX PARTE* QUAYLE OFFICE ACTION**

Sir:

In response to the *Ex Parte Quayle* Office Action dated September 13, 2006, applicants submit the following amendments and remarks for entry of record in the above-identified patent application.

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**CERTIFICATION OF ELECTRONIC TRANSMISSION**

I hereby certify that this paper is being electronically transmitted to the Patent and Trademark Office on the date shown below.

Dated: October 16, 2006

  
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Leslie S. Szivos